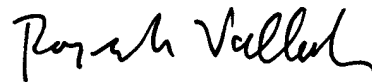


Remarks

New claims 27-50 are added to more fully cover the embodiment of the invention directed to a mask for vapor hydrogen fluoride etching. Entry of this amendment is requested prior to initial examination of this application.

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Respectfully submitted,



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Rajesh Vallabh  
Reg. No. 35,761  
for Wayne M. Kennard  
Reg. No. 30,271  
Attorney for Applicant

Hale and Dorr LLP  
60 State Street  
Boston, Massachusetts 02109  
Tel: (617) 526-6505